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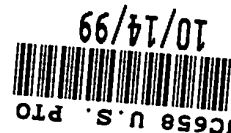
Patent No. CS99-120

Sir:

Transmitted herewith for filing is the Patent Application of:

Inventor: LAP CHAN, CHER LIANG CHA AND KHENG CHOK TEE

For: A NEW METHOD TO FORM A CROSS NETWORK OF AIR GAPS WITHIN IMD LAYER



Enclosed are:

- ☒ 7 sheets of drawing(s) - formal.
- ☒ An assignment of the invention to Chartered Semiconductor Manufacturing Ltd. And National University of Singapore
- ☐ An associate power of attorney

The filing fee has been calculated as shown below:

	(Col. 1)	(Col. 2)	OTHER THAN A SMALL ENTITY	
FOR:	NO. FILED	NO. EXTRA	RATE	FEE
BASIC FEE				\$ 760.
TOTAL CLAIMS	28 -20=	8	x 18 =	\$ 144.
INDEP CLAIMS	4 -3=	1	x 78 =	\$ 78.
MULTIPLE DEPENDENT CLAIM PRESENTED			+ 260 =	
			SUB TOTAL	\$ 982.
			ASSIGNMENT	\$40.
			TOTAL	\$ 1,022.

- ☒ Please charge my Deposit Account No. 19-0033 in the amount of \$ 1,022. A duplicate copy of this sheet is enclosed.
- ☒ The Commissioner is hereby authorized to charge payment of the following fees associated with this communication or credit any overpayment to Deposit Account No. 19-0033. A duplicate copy of this sheet is enclosed.
- ☒ Any additional filing fees required under 37 CFR \$1.16.
- ☒ Any patent application processing fees under 37 CFR \$1.17.

Respectfully submitted,

GEORGE C. SAILE, REG. NO. 19,572